

Amendments to the Specification:

Please replace the paragraph at page 1, lines 8-12, of the specification with the following amended paragraph:

This application is a division of Application No. 10/144,025, filed May 14, 2002, which is based upon and claims the benefit of priority from the prior Japanese Patent Application No. 2001-143682, filed May 14, 2001, ~~the entire contents~~ all of which are incorporated herein by reference.

Please replace the paragraph at page 85, lines 12-23, of the specification with the following amended paragraph:

Subsequently, as shown in FIGS. 16B, 16C, a linear developing solution supply nozzle 711 is scanned from one end to the other end of the substrate 700, the developing solution is discharged in a curtain form via a supply port of the developing solution supply nozzle 711, and a developing solution film ~~[[762]]~~ 731 is formed on the substrate 700. Additionally, FIG. 16B is a plane view, and FIG. 16C is a sectional view of FIG. 16B. For the developing solution supply nozzle 711 of the seventh embodiment, a supply amount distribution of a direction (depth direction of the drawing surface) vertical to the scanning direction is kept constant.

Please replace the paragraph at page 88, lines 2-11, of the specification with the following amended paragraph:

When the developing solution supply nozzle 711 supplies the developing solution, and the developing solution supply nozzle 711 is scanned from one end to the

other end of the substrate 700 to form the developing solution film, the thickness of the developing solution film ~~[[762]]~~ 731 is determined by the relative speed of the scanning speed of the developing solution supply nozzle 711 and the supply speed of the developing solution from the developing solution supply nozzle 711.